

DECLARATION IN <input checked="" type="checkbox"/> ORIGINAL <input type="checkbox"/> NATIONAL STAGE OF PCT APPLICATION <input type="checkbox"/> DIVISIONAL <input type="checkbox"/> CONTINUATION <input type="checkbox"/> CONTINUATION-IN-PART	Attorney Docket No.
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SPECIFICATION AND INVENTORSHIP IDENTIFICATION

As a below named inventor, I declare that:

My residence, post office address and citizenship are as stated below next to my name.

I believe I am the original, first and ☐ sole ☒ joint inventor of the subject matter which is claimed, and for which a patent is sought, on the invention entitled:

MULTI-LAYERED SUBSTRATE WITH A BUILT-IN CAPACITOR DESIGN AND A METHOD OF MAKING THE SAME

, the specification of which;

- ☒ is attached hereto
- ☐ was filed on _____ as Appln. Serial No. _____
- ☐ and was amended on _____
- ☐ was described and claimed in PCT International Application No. _____, filed on _____
- ☐ and was amended under PCT Article 19 on _____

ACKNOWLEDGEMENT OF REVIEW OF PAPERS AND DUTY OF CANDOR

I have reviewed and understand the contents of the above identified specification, including the claims, as amended by any amendment referred to above. I acknowledge the duty to disclose information which is known to me to be material to the patentability of this application in accordance with Title 37, Code of Federal Regulations, § 1.56.

PRIORITY CLAIM (35 USC § 119)

I claim foreign priority benefits under Title 35, United States Code, § 119 of any foreign application(s) for patent or inventor's certificate listed below and have also identified below any foreign application for patent or inventor's certificate having a filing date before that of the application on which priority is claimed:

Prior Foreign Application(s)

Number	Country	Day/Month/Year Filed	Priority Claimed
_____	_____	_____	<input type="checkbox"/> Yes <input type="checkbox"/> No
_____	_____	_____	<input type="checkbox"/> Yes <input type="checkbox"/> No
_____	_____	_____	<input type="checkbox"/> Yes <input type="checkbox"/> No

PRIORITY CLAIM (35 USC § 120)

I claim the benefit under Title 35, United States Code, § 120 of any United States application(s) listed below. Insofar as the subject matter of each of the claims of this application is not disclosed in the prior United States application in the provided by the first paragraph of Title 35 United States Code § 112, I acknowledge the duty to disclose to the Patent Office all information known to me to be material to patentability as defined in Title 37 Code of Federal Regulations § 1.56 which became available between the filing date of the prior application and the national of PCT international filing date of this application:

U.S. Serial No.	International Appln. No. (under PCT)	Filing Date	Status(patented, pending, abandoned)
_____	_____	_____	_____
_____	_____	_____	_____

DECLARATION

I declare that all statements made herein that are of my own knowledge are true and that all statements that are made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

DESIGNATION OF CORRESPONDENCE ADDRESS

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Full name of sole or first joint inventor: Chen-Wen TSAI

Signature: Chen-Wen TSAI Date: 1/26, 00

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Full name of second joint inventor: Chung-Ju WU

Signature: Chung-Ju WU Date: Jan. 26, 2000

Residence: 5F-7, NO.31, JUL YUAN RD., CHIEN CHIN DIST., KAOHSIUNG, TAIWAN, R.O.C.

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